

θx , θy axes | S37.T6S/KF

Piezo Tip/Tilt Platform



Introduction

S37.T6 piezo tip/tilt platform is specially designed for vibrating environments, with anti-vibration properties, and adopt a fully closed loop method, which can provide higher positioning accuracy.

Characteristics >>

- θx, θy tilt
- Anti-vibration design
- · High reliability
- Optional open/closed loop

Applications >>

- Optical trapping
- Image processing and stabilization
- · Laser tuning
- · Laser scanning/beam deflection
- Beam stability
- Optical
- Light filter/optical switch





Technical Data >>

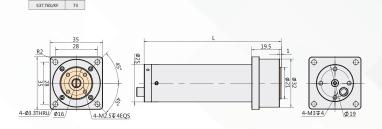
	<u></u>	AUT CONTRACTOR OF THE PROPERTY		
Туре	S - closed loop K - open loop	S37.T6SF	S37.T6KF	Units
Active axes		Өх, Өу	Өх, Өу	
Driving channels		3	3	
Tilt angle(0~120V)		7.5/±3.75	7.5/±3.75	mrad±20%
Tilt angle(0~150V)		10/±5	10/±5	mrad±20%
Integrated sensor		SGS	-	
Resolution		0.25 (≈ 0.05")	0.08 (≈ 0.02")	μrad
Closed-loop linearity		0.1	-	%F.S.
Closed-loop repeatability		0.02	-	%F.S.
Unloaded resonant frequency		6.1		kHz±20%
El. capacitance		11		μF±20%
Operating temperature ^[1]		-20~80		℃
Material		Steel, titanium		
Mass		300		g±5%
Platform Length		73		mm±0.1
Cable length ^[2]		1.5		m±10mm
Sensor/voltage connector ^[2]		-		

Note: Technical data are measured by CoreMorrow E00/E01 series piezo controller. Max driving voltage could be -20V~150V, 0~120V is recommended for long-term and high-reliable operation. Unless otherwise specified, the above parameters are measured at room temperature about 25° C.

- [1] Custom ultralow temperature and ultrahigh vacuum versions are available.
- [2] Custom cable length and connector is available.

Note: The parallelism of the moving platform is about $20\mu m$, and the roughness is about 1.6 to 3.2. Please contact the sales engineer for confirmation before purchase.

Drawing >>



Recommended Controllers >>



E01.D3 LCD, membrane button, up to 625mA RS-232/RS-422/USB interface Software secondary development



E70 Small size, ave current 70mA/channel RS-232/RS-422/USB interface Software secondary development

